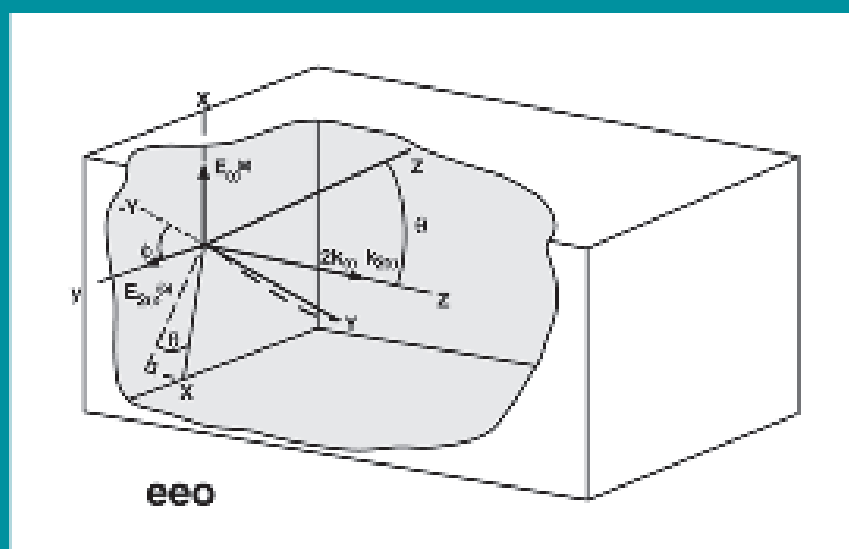


Handbook of Nonlinear Optics

Second Edition, Revised and Expanded



Richard L. Sutherland

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Second Edition, Revised and Expanded

Richard L. Sutherland

*Science Applications International Corporation
Dayton, Ohio, U.S.A.*

with contributions by

Daniel G. McLean

*Science Applications International Corporation
Dayton, Ohio, U.S.A.*

Sean Kirkpatrick

*Air Force Research Laboratory
Wright Patterson Air Force Base, Ohio, U.S.A.*



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